Electronic Acknowledgement Receipt				
EFS ID:	1375649			
Application Number:	10537385			
International Application Number:				
Confirmation Number:	4538			
Title of Invention:	Growth of planar, non-polar a-plane gallium nitride by hydride vapor phase epitaxy			
First Named Inventor/Applicant Name:	Benjamin A. Haskell			
Customer Number:	22462			
Filer:	George Henry Gates			
Filer Authorized By:				
Attorney Docket Number:	30794.74USWO			
Receipt Date:	14-DEC-2006			
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Application Type:	U.S. National Stage under 35 USC 371			

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File Listing:

Document Number	Document Description	File Name	File Size(Bytes)	Multi Part /.zip	Pages (if appl.)
1	Miscellaneous Incoming Letter	TransmittalGeneral2006-12- 14.pdf	92110	no	1
Warnings:					

Information:					
2	Information Disclosure Statement (IDS) Filed	IDS2006-12-14.pdf	5169341	no	4
Warnings:					
Information:					
		Total Files Size (in bytes):	5261451		

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New Applications Under 35 U.S.C. 111

If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

National Stage of an International Application under 35 U.S.C. 371

If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.